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PATENT
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IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: AHN, Byung Yong Conf.: 3449
Appl. No.: 09/747,928 Group: 1765
Filed: December 27, 2000 Examiner: Binh X. Tran
For: DRY ETCHING METHOD AND APPARATUS FOR USE IN THE LCD
DEVICE

AMENDMENT

Honorable Commissioner of Patents
Washington, D.C. 20231

December 24, 2002

Sir:

In response to the Examiner's Office Action dated September 25, 2002, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

In the Claims:

Please cancel claims 1-6, 18 and 21-23 without prejudice or disclaimer of the subject matter contained therein.

Please amend the claims as follows:

7. (Amended) A method for preventing an array substrate from being
AI damaged due to an electrostatic force after a dry-etching process, comprising: